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(71) Applicant (for all designated States except US): PCBU SERVICES, INC. [US/US]; 300 Delaware Ave., Suite 1269, Wilmington, DE 19801 (US).

(72) Inventors; and

(75) Inventors/Applicants (for US only): BOGGS, Janet [US/US]; 6925 N. 900 East, Brownsburg, IN 46112 (US). BRANDSTADTER, Stephan, M. [US/US]; 3946 N. Washington Blvd., Indianapolis, IN 47906 (US). CHIEN, John [US/US]; 3318 Humbolt Street, West Lafayette, IN 47906 (US). SHARMA, Vimal [IN/US]; 2101 Cumberland Avenue, 5104, West Lafayette, IN 47906 (US). EDWARDS, Bradley, E. [US/US]; 3704 Woodcliff Drive,

Lafayette, IN 47905 (US). HEDRICK, Victoria [US/US]; 9262 South 300 E., Brookston, IN 47923 (US). JACKSON, Andrew [US/US]; 3346 Whirl Away Court, West Lafayette, IN 47906 (US). LEMAN, Gregory [US/US]; 3319 Crawford Street, West Lafayette, IN 47906 (US). NORMAN, Edward [US/US]; 942 St. Matthews Road, Chester Springs, PA 19425 (US). KAUFMAN, Robert [US/US]; 8129 Stanford Ave., St. Louis, MO 63130 (US).

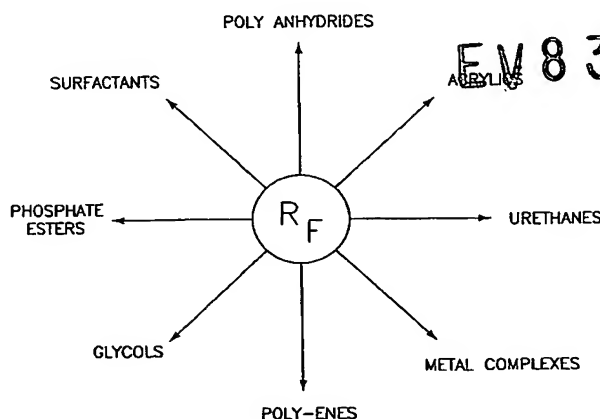
(74) Agents: HYTA, Robert, C. et al.; Well St. John, P.S., 601 West First Street, Suite 1300, Spokane, WA 99201-3828 (US).

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(54) Title: PRODUCTION PROCESSES AND SYSTEMS, COMPOSITIONS, SURFACTANTS, MONOMER UNITS, METAL COMPLEXES, PHOSPHATE ESTERS, GLYCOLS, AQUEOUS FILM FORMING FOAMS, AND FOAM STABILIZERS



(57) Abstract: Production processes and systems are provided that include reacting halogenated compounds, dehalogenating compounds, reacting alcohol's, reacting olefins and a saturated compounds, reacting reactants having at least two -CF₃ groups with reactants having cyclic groups. R_F-compositions such as R_F-intermediates, R_F-surfactants, R_F-monomers, R_F-monomer units, R_F-metal complexes, R_F-phosphate esters, R_F-glycols, R_F-urethanes, and/or R_F-foam stabilizers. The R_F portion can include at least two -CF₃ groups, at least three -CF₃ groups, and/or at least two -CF₃ groups and at least two -CH₂- groups. Detergents, emulsifiers, paints, adhesives, inks, wetting agents, foamers, and defoamers including the R_F-surfactant composition are provided. Acrylics, resins, and polymers are provided that include a R_F-monomer unit. Compositions are provided that include a substrate having a R_F-composition thereover. Aqueous Film Forming Foam ("AFFF") formulations are provided that can include R_F-surfactants and/or R_F-foam stabilizers are provided.

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